

Growth of single phase tetragonal structure iron tantalum oxide thin films grown by sol-gel spin coating technique

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The above article was submitted and published in JMSL 20 (2001) 969 with an unintentional mistake: Fig. 5 is incorrect. The correct figure is reproduced below with a

modified caption. The author apologises for any inconvenience or embarrassment caused.

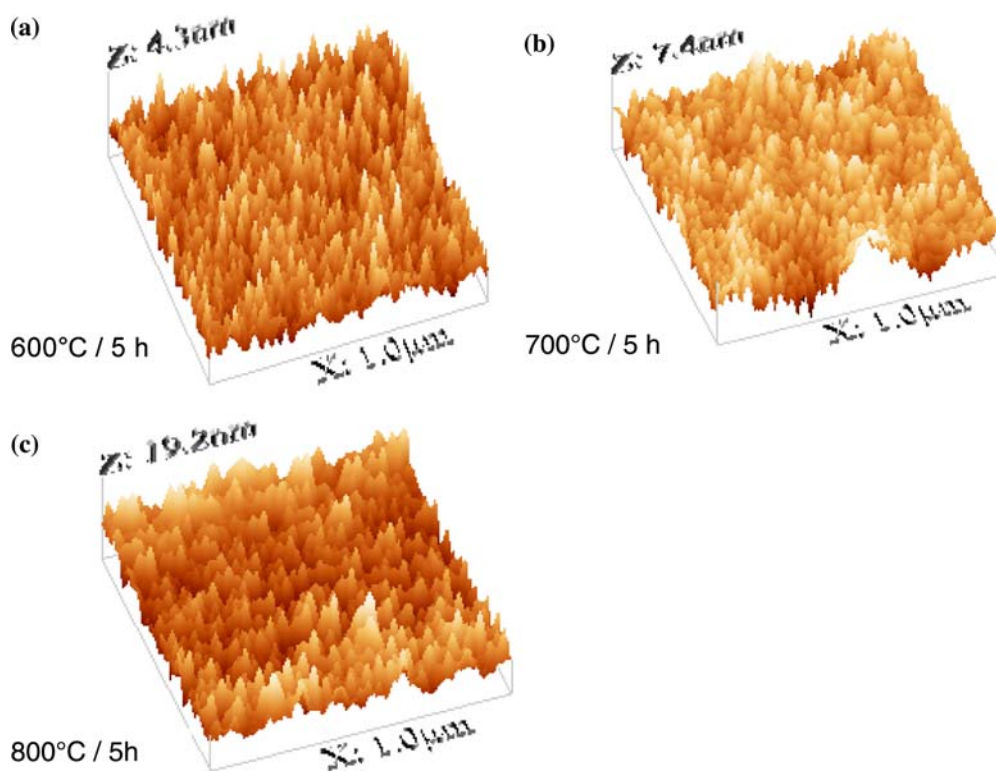


Fig. 5 Atomic Force microscopy images of $\text{Fe}_2\text{Ta}_2\text{O}_8$ thin films deposited on Si (100) annealed at (a) 600°C/5 h, (b) 700°C/5 h and (c) 800°C/5 h

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